



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: 1756

Application Number: 10/670,291

Examiner: **Daborah Chacko-Davis**

Filed: **September 26, 2003**

Confirmation Number: 6427

For: **RESIST PATTERN THICKENING MATERIAL, PROCESS FOR
FORMING RESIST PATTERN, AND PROCESS FOR
MANUFACTURING SEMICONDUCTOR DEVICE**

Attorney Docket Number: 031181

Customer Number: 38834

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

December 22, 2006

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated August 22, 2006 for one month from November 22, 2006 to December 22, 2006.

Attached please find a check in the amount of \$120.00 for the cost of the extension. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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